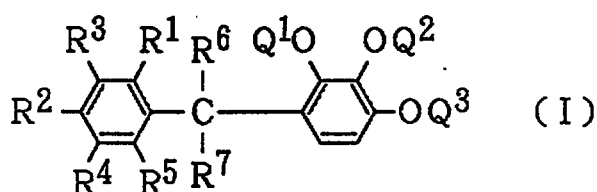


A B S T R A C T

A compound represented by the general formula (I):



wherein one of R^1 and R^2 represents $-\text{OQ}^4$ and the other represents hydrogen, alkyl, cycloalkyl, alkenyl, alkoxy or halogen; R^3 , R^4 and R^5 each independently represent hydrogen, alkyl, cycloalkyl, alkenyl, alkoxy or halogen; provided that when R^2 is $-\text{OQ}^4$, both of R^3 and R^4 are hydrogen or at least one of R^1 and R^5 is alkyl, cycloalkyl, alkenyl, alkoxy; R^6 and R^7 each independently represent hydrogen, alkyl or alkenyl, or R^6 and R^7 form a cycloalkane ring; and Q^1 , Q^2 , Q^3 and Q^4 each independently represent hydrogen or o-quinonediazide sulfonyl, provided that at least one of Q^1 , Q^2 , Q^3 and Q^4 is o-quinonediazide sulfonyl; a process for producing the same; a photosensitizer comprising the same; and a positive resist composition comprising the same; and

1,2,3-Trihydroxy-4-(4-hydroxy-2,5-dimethylbenzyl) benzene and a positive resist composition comprising the same.

8-2201072

